Special Issue

Recent Advances in Plasmonics and Nanophotonics

Message from the Guest Editors

This Special Issue aims to provide an overview of the latest advances in fundamentals and applications of plasmonics and nanophotonics. All aspects of optics at the nanoscale are welcome, including, but not limited to, the following topics:

- Physical optics of nanostructures
- Nanoplasmonics
- Nonlinear optics of nanostructures
- Quantum, nonlinear and nonlocal effects in plasmonic nanostructures
- All-dielectric metasurfaces
- Nanoantennas and Mie resonators
- Optothermal properties of photonic nanostructures
- Metamaterials, metasurfaces, photonic crystals, and nanostructured diffraction gratings
- Nanowaveguides
- Theory and modeling of photonic nanostructures
- Photonics of 2D materials
- Nanofabrication techniques

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Deadline for manuscript submissions

closed (30 June 2020)



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Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multidimensional network.

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